

The 2010 International Meeting for Future of Electron Devices, Kansai

May 13-14, 2010, Kansai University Centenary Memorial Hall, Osaka, Japan

<http://www.imfedk.org/>

Conference Theme:

“Electron Devices for Future Safe and Comfortable Society”

General Chair

Yoichi Akasaka

Guest Professor & Former Professor of Osaka University

Executive Committee Chair

Tadashi Nishimura

Renesas Technology Corp.

Further Information

Please contact Dr. Yasuo Inoue for more information.

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Kansai University Centenary Memorial Hall

Committee members

Tanemasa Asano,	Kyushu University
Hiroyuki Fujii,	KYOCERA Display Institute Co., Ltd.
Hideki Hayashi,	Sumitomo Electric Corp.
Akira Hiroki,	Kyoto Institute of Technology
Makoto Inai,	Murata Manufacturing Co., Ltd.
Yasuo Inoue,	Renesas Technology Corp.
Takashi Ipposhi,	Renesas Technology Corp.
Yoshinari Kamakura,	Osaka University
Akira Kamisawa,	ROHM CO., LTD.
Mutsumi Kimura,	Ryukoku University
Tsunenobu Kimoto,	Kyoto University
Junko Komori,	Renesas Technology Corp.
Hiroshi Kotaki,	SHARP Corp.
Masaaki Kuzuhara,	Fukui University
Naoto Matsuo,	University of Hyogo
Toshimasa Matsuoka,	Osaka University
Takashi Minemoto,	Ritsumeikan University
Seiichi Miyazaki,	Hiroshima University
Masahiro Moniwa,	Renesas Technology Corp.
Takashi Nakamura,	ROHM CO., LTD.
Michinori Nishihara,	IBM Japan
Minoru Noda,	Kyoto Institute of Technology
Shinji Odanaka,	Osaka University
Matsuo Ogawa,	Kobe University
Yasuhisa Omura,	Kansai University
Hirokyki Sakai,	Panasonic Corp.
Shigehiko Sasa,	Osaka Institute of Technology
Tomonori Seki,	OMRON Corp.
Akira Takahashi,	SHARP Corp.
Yukiharu Uraoka,	Nara Institute of Science and Technology
Hirobumi Watanabe,	Ricoh Co., Ltd.
Masahiro Yoshimoto,	Kyoto Institute of Technology

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The meeting covers all areas of electron devices: Si-devices, compound semiconductor devices, emerging solid-state devices, and related modeling, simulation, characterization, material & process technologies.

Location

Osaka is one of the best sightseeing spots in Japan. Detailed access map to Kansai University Centenary Memorial Hall is available at

<http://www.kansai-u.ac.jp/global/guide/mapsenri.html>

http://www.kansai-u.ac.jp/English/about_ku/senri_map.html

Official Language

English will be used for all printed materials, presentation and discussion, except tutorials.

Paper Submission

Submission will be received from Jan. 5 through **Feb. 3, 2010**.

Result of paper selection will be sent to the author by the end of Feb.

IEEE EDS Kansai Chapter IMFEDK Awards

(Best Paper, Student Paper)

The IMFEDK Awards will be awarded to the excellent papers written and presented by IEEE members. Only the first author, in the case of Student Paper Award, is honored with testimonials during the IMFEDK Meeting.